L Number	Hits	Search Text	DB	Time stamp
l	336	ALD and plasma and silicide	USPAT;	2004/10/22 13:27
		1	US-PGPUB;	
`			EPO;	
			DERWENT;	
			IBM TDB	
2	0	20020197881.URPN.	USPAT	2004/10/22 11:46
3	0	20020146895.URPN.	USPAT	2004/10/22 11:50
4	0	6709989.URPN.	USPAT	2004/10/22 12:03
12	403	plasma and (atomic adj layer adj deposition) and silicide	USPAT;	2004/10/22 12:03
12	103	plasma and (atomic adjulyer adjucposicion) and sincide	US-PGPUB;	200 1/10/22 13.10
			EPO;	
			DERWENT;	
			IBM TDB	
13	97	(plasma and (atomic adj layer adj deposition) and	USPAT;	2004/10/22 14:00
13	71	silicide) not (ALD and plasma and silicide)	US-PGPUB;	2004/10/22 14.00
		sincide) not (ALD and plasma and sincide)	EPO;	
			DERWENT;	· ·
21	511	420/602 -	IBM_TDB	2004/10/20 14 01
21	511	438/682.ccls.	USPAT;	2004/10/22 14:01
			US-PGPUB;	
			EPO;	
			DERWENT;	
00	0	490/600 -1 1/11 / / 11 11	IBM_TDB	0004/10/00 14 01
22	8	438/682.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 14:01
		deposition))	US-PGPUB;	
			EPO;	
			DERWENT;	
00	0	(40.0/2.00 1 1/11 /	IBM_TDB	0004/10/00 14 01
23	3	(438/682.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 14:01
		deposition))) not (ALD and plasma and silicide) not	US-PGPUB;	
		((plasma and (atomic adj layer adj deposition) and	EPO;	
		silicide) not (ALD and plasma and silicide))	DERWENT;	
	(50	400/600 1	IBM_TDB	0004/10/00 14 00
24	653	438/683.ccls.	USPAT;	2004/10/22 14:02
			US-PGPUB;	
			EPO;	
			DERWENT;	
25	10	420/60211 (-11 (-4	IBM_TDB	0004/10/00 14 00
25	13	438/683.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 14:02
		deposition))	US-PGPUB;	
			EPO;	
			DERWENT;	•
26	A	(429/692 colo and /ald == /=+===!= = 4:1	IBM_TDB	2004/10/00 14 00
26	4	(438/683.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 14:02
		deposition))) not (438/682.ccls. and (ald or (atomic adj	US-PGPUB;	
		layer adj deposition))) not (ALD and plasma and silicide)	EPO;	
	.	not ((plasma and (atomic adj layer adj deposition) and	DERWENT;	
27	(14	silicide) not (ALD and plasma and silicide))	IBM_TDB	2004/10/22 14 42
27	644	438/685.ccls.	USPAT;	2004/10/22 14:48
		_	US-PGPUB;	
			EPO;	
			DERWENT;	
		490/205	IBM_TDB	0004/10/00 - 11
28	47	438/685.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 14:48
		deposition))	US-PGPUB;	
			EPO;	
			DERWENT;	
			IBM_TDB	

	T	20 1	(400/c0r 1, 1/11 / , : 1:1	LICDAT	2004/10/22 14:40
29	3	33	(438/685.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 14:49
			deposition))) not (438/683.ccls. and (ald or (atomic adj	US-PGPUB;	
			layer adj deposition))) not (438/682.ccls. and (ald or	EPO;	
			(atomic adj layer adj deposition))) not (ALD and plasma	DERWENT;	
			and silicide) not ((plasma and (atomic adj layer adj	IBM_TDB	
			deposition) and silicide) not (ALD and plasma and		
	_	_	silicide))	LICDATE	0004/10/00 14 40
30	9	99	("4796082"	USPAT;	2004/10/22 14:42
			"5593562"	US-PGPUB;	
			"4568960"	EPO;	
			"5217943"	DERWENT;	
			"6576062"	IBM_TDB	
			"6773970"		
			"6703296"		
		- 1	"5320880"		•
		- 1	"5652181"		
			"5882399"		
			"6420260"		
			"4557943"		
ı			"4617237"		
			"4443930"		
			"4568565"		
			"5719410"		
			"4978420"		
			"5236868"		
			"5403435"		
			"5478780"		
			"5928966"		
			"6100193"		
			"4411734"		
			"5246887"		
		l	"5344792"		
			"5554488"		
		.	"5686761"		
			"5693562"		
			"5736455"		
			"5801095"		
			"5849092"		
			"5904561"		
			"5926743"		
			"5933760"		
			"5990493"		
			"5994211"		
			"6026762"		
			"6117345"		
			"6146988"		
			"6204550"		
			"4453305"		
			"4464701"		
			"4570328"		
			"4605947"		
			"4777061"		
			"4777150"		
			"4786360"		,
		ł	"4795722"		
			"4839304"		
			"4894693").pn.		
I					

31	312	420/00/1-	USPAT;	2004/10/22 14.50
31	312	438/686.ccls.	US-PGPUB;	2004/10/22 14:50
			EPO;	
		•	DERWENT;	
			IBM TDB	
32	22	438/686.ccls. and (ald or (atomic adj layer adj	USPĀT;	2004/10/22 14:51
		deposition))	US-PGPUB;	
		-	EPO;	
			DERWENT;	
			IBM_TDB	
33	14	(438/686.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 14:51
		deposition))) not (438/685.ccls. and (ald or (atomic adj	US-PGPUB;	
		layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and	EPO; DERWENT;	
-		(ald or (atomic adj layer adj deposition))) not (ALD and	IBM_TDB	
		plasma and silicide) not ((plasma and (atomic adj layer	IDM_IDB	
		adj deposition) and silicide) not (ALD and plasma and		
		silicide))		
34	9	((438/686.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 14:51
		deposition))) not (438/685.ccls. and (ald or (atomic adj	US-PGPUB;	
		layer adj deposition))) not (438/683.ccls. and (ald or	EPO;	
		(atomic adj layer adj deposition))) not (438/682.ccls. and	DERWENT;	
		(ald or (atomic adj layer adj deposition))) not (ALD and	IBM_TDB	
		plasma and silicide) not ((plasma and (atomic adj layer		
		adj deposition) and silicide) not (ALD and plasma and silicide))) and plasma		
35	577	438/597.ccls.	USPAT;	2004/10/22 14:51
]	130/371.0013.	US-PGPUB;	2004/10/22 14.51
			EPO;	
			DERWENT;	
			IBM_TDB	
36	8	438/597.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 14:51
		deposition))	US-PGPUB;	
			EPO;	
			DERWENT; IBM TDB	
37	4	(438/597.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 14:51
, 3,		deposition))) not (438/686.ccls. and (ald or (atomic adj	US-PGPUB;	2004/10/22 14.51
		layer adj deposition))) not (438/685.ccls. and (ald or	EPO;	
		(atomic adj layer adj deposition))) not (438/683.ccls. and	DERWENT;	
·		(ald or (atomic adj layer adj deposition))) not	IBM_TDB	
		(438/682.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (ALD and plasma and silicide) not		
		((plasma and (atomic adj layer adj deposition) and		
38	,	silicide) not (ALD and plasma and silicide))	LICDAT.	2004/10/22 14:52
30	'	((438/597.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj	USPAT; US-PGPUB;	2004/10/22 14:52
		layer adj deposition))) not (438/685.ccls. and (ald or	EPO;	
		(atomic adj layer adj deposition))) not (438/683.ccls. and	DERWENT;	
		(ald or (atomic adj layer adj deposition))) not	IBM_TDB	
		(438/682.ccls. and (ald or (atomic adj layer adj	_	
		deposition))) not (ALD and plasma and silicide) not		
		((plasma and (atomic adj layer adj deposition) and		.
00		silicide) not (ALD and plasma and silicide))) and plasma		
39	194	438/630.ccls.	USPAT;	2004/10/22 14:52
			US-PGPUB;	[
			EPO; DERWENT;	
			IBM TDB	
·	L		יייייייי דייייייי	<u> </u>

40	4	438/630.ccls. and (ald or (atomic adj layer adj deposition))	USPAT; US-PGPUB;	2004/10/22 14:52
		,,,	EPO;	
	,		DERWENT;	
	_		IBM_TDB	
41	2	(438/630.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 14:52
		deposition))) not (438/597.ccls. and (ald or (atomic adj	US-PGPUB; EPO;	
		layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and	DERWENT;	
,		(ald or (atomic adj layer adj deposition))) not	IBM TDB	
		(438/683.ccls. and (ald or (atomic adj layer adj	12122	
		deposition))) not (438/682.ccls. and (ald or (atomic adj	,	
		layer adj deposition))) not (ALD and plasma and silicide)		
		not ((plasma and (atomic adj layer adj deposition) and		
	_	silicide) not (ALD and plasma and silicide))		
42	1	((438/630.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 14:52
		deposition))) not (438/597.ccls. and (ald or (atomic adj	US-PGPUB; EPO;	
		layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and	DERWENT;	
		(ald or (atomic adj layer adj deposition))) not	IBM_TDB	
•		(438/683.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/682 ccls. and (ald or (atomic adj		
		layer adj deposition))) not (ALD and plasma and silicide)		
		not ((plasma and (atomic adj layer adj deposition) and		
40	700	silicide) not (ALD and plasma and silicide))) and plasma	LICDATE	0004/10/00 14 50
43	728	438/648.ccls.	USPAT; US-PGPUB;	2004/10/22 14:58
		•	EPO;	
•			DERWENT;	
			IBM TDB	
44	21	438/648.ccls. and (ald or (atomic adj layer adj	USPĀT;	2004/10/22 14:58
		deposition))	US-PGPUB;	
			EPO;	
	1		DERWENT;	
45	13	(438/648.ccls. and (ald or (atomic adj layer adj	IBM_TDB USPAT;	2004/10/22 14:59
13		deposition))) not (438/630.ccls. and (ald or (atomic adj	US-PGPUB;	2004/10/22 14.39
		layer adj deposition))) not (438/597.ccls. and (ald or	EPO;	
		(atomic adj layer adj deposition))) not (438/686.ccls. and	DERWENT;	
		(ald or (atomic adj layer adj deposition))) not	IBM_TDB	
		(438/685.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/683.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma		
		and silicide) not ((plasma and (atomic adj layer adj		
		deposition) and silicide) not (ALD and plasma and		
		silicide))		
46	4	((438/648.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 14:59
		deposition))) not (438/630.ccls. and (ald or (atomic adj	US-PGPUB;	
		layer adj deposition))) not (438/597.ccls. and (ald or	EPO;	
		(atomic adj layer adj deposition))) not (438/686.ccls. and	DERWENT;	
		(ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj	IBM_TDB	
		deposition))) not (438/683.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/682.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (ALD and plasma		
		and silicide) not ((plasma and (atomic adj layer adj		
		deposition) and silicide) not (ALD and plasma and		
		silicide))) and plasma	<u></u>	

47	5:00
48 4 438/649.ccls. and (ald or (atomic adj layer adj deposition)) 49 1 (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/680.ccls. and (ald or (atomic adj layer adj deposition))) not (438/680.ccls. and (ald or (atomic adj layer adj deposition))) not (438/680.ccls. and (ald or (atomic adj layer adj deposition))) not (438/680.ccls. and (ald or (atomic adj layer adj deposition))) not (438/680.ccls. and (ald or (atomic adj layer adj deposition))) not (438/680.ccls. and (ald or (atomic adj layer adj deposition))) not (438/680.ccls. and (ald or (atomic adj layer adj deposition))) not (438/680.ccls. and (ald or (atomic adj layer adj deposition))) not (438/680.ccls. and (ald or (atomic adj layer adj deposition))) not (438/680.ccls. and (ald or (atomic adj layer adj deposition)) not (438/680.ccls. and (ald or (atomic adj layer adj deposition))) not (438/680.ccls. and (ald or (atomic adj layer adj deposition)) not (438/680.ccls. and (ald or (atomic adj layer adj deposition)) not (438/680.ccls. and (ald or (atomic adj layer adj deposition)) not (438/680.ccls. and (ald or (atomic adj layer adj deposition)) not (438/680.ccls. and (ald or (atomic adj layer adj deposition)) not (438/680.ccls. and (ald or (atomic adj layer adj deposition)) not (438/680.ccls. and (ald or (atomic adj layer adj deposition)) and blasma and silicide) not ((plasma and (atomic adj layer adj deposition)) and blasma and silicide) not ((pl	
48 4 438/649.ccls. and (ald or (atomic adj layer adj deposition)) 49 1 (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide)) 50 1 ((438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/686.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition)) not (ALD and plasma and silicide)) and plasma and silicide) not ((plasma and (atomic adj layer adj deposition)) not (atomic adj layer adj deposition) not (atomic adj layer adj deposition) not (atomic	
48 4 438/649.ccls. and (ald or (atomic adj layer adj deposition)) 49 1 (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/680.ccls. and (ald or (atomic adj layer adj deposition))) not (438/690.ccls. and (ald or (atomic adj layer adj deposition))) not (438/690.ccls. and (ald or (atomic adj layer adj deposition))) not (438/697.ccls. and (ald or (atomic adj layer adj deposition))) not (438/697.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/690.ccls. and (ald or (atomic adj layer adj deposition))) not (438/690.ccls. and (ald or (atomic adj layer adj deposition))) not (438/690.ccls. and (ald or (atomic adj layer adj deposition))) not (438/690.ccls. and (ald or (atomic adj layer adj deposition))) not (438/690.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/690.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition)) not (438/682.ccls. and (ald or (atomic adj layer adj deposition)) not (438/682.ccls. and (ald or (atomic adj layer adj deposition)) not (A120 and plasma and silicide)) and plasma and silicide) not ((plasma and (atomic adj layer adj deposition))) not (A120 and plasma and silicide)) and plasma 51 155 438/650.ccls.	
48 4 438/649.ccls. and (ald or (atomic adj layer adj deposition)) 49 1 (438/649.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/697.ccls. and (ald or (atomic adj layer adj deposition))) not (438/687.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (428/683.ccls. and (ald or (atomic adj layer adj deposition))) not (428/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/648.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/685.ccls. and (ald or (atomic adj layer adj deposition))) not (438/632.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition)) not (438/682.ccls. and (ald or (atomic adj layer adj deposition)) not (438/682.ccls. and (ald or (atomi	
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layer adj deposition))) not (438/683.ccls. and (ald or (atomic adj layer adj deposition))) not (438/682.ccls. and (ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))) and plasma 151	
(ald or (atomic adj layer adj deposition))) not (ALD and plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))) and plasma 151 155 438/650.ccls. USPAT; 2004/10/22 15:0	
plasma and silicide) not ((plasma and (atomic adj layer adj deposition) and silicide) not (ALD and plasma and silicide))) and plasma 151	
adj deposition) and silicide) not (ALD and plasma and silicide))) and plasma 151	•
silicide))) and plasma 51	
51 155 438/650.ccls. USPAT; 2004/10/22 15:0	
US-PGPUB:	i:01
EPO;	
DERWENT;	
IBM_TDB	
52 11 438/650.ccls. and (ald or (atomic adj layer adj USPAT; 2004/10/22 15:0	:01
deposition)) US-PGPUB;	
EPO;	
DERWENT;	
1 (438/650.ccls. and (ald or (atomic adj layer adj USPAT; deposition))) not (438/649.ccls. and (ald or (atomic adj US-PGPUB;	:.01
layer adj deposition))) not (438/648.ccls. and (ald or EPO;	5:01
(atomic adj layer adj deposition))) not (438/630.ccls. and DERWENT;	5:01
(ald or (atomic adj layer adj deposition))) not IBM_TDB	5:01
(438/597.ccls. and (ald or (atomic adj layer adj	5:01
deposition))) not (438/686.ccls. and (ald or (atomic adj	5:01
layer adj deposition))) not (438/685.ccls. and (ald or	5:01
(atomic adj layer adj deposition))) not (438/683.ccls. and	5:01
(ald or (atomic adj layer adj deposition))) not	5:01
(438/682.ccls. and (ald or (atomic adj layer adj	5:01
deposition))) not (ALD and plasma and silicide) not	5:01
((plasma and (atomic adj layer adj deposition) and	5:01
silicide) not (ALD and plasma and silicide))	5:01

54		((420/650 cale and (ald an (at a standard 1))	LICDATE	0004/10/00 15 00
54	0	((438/650.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:02
		deposition))) not (438/649.ccls. and (ald or (atomic adj	US-PGPUB;	
	ļ	layer adj deposition))) not (438/648.ccls. and (ald or	EPO;	
	ļ	(atomic adj layer adj deposition))) not (438/630.ccls. and	DERWENT;	
		(ald or (atomic adj layer adj deposition))) not	IBM_TDB	
•		(438/597.ccls. and (ald or (atomic adj layer adj		
	1	deposition))) not (438/686.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/685.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/683.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/682.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (ALD and plasma and silicide) not		
		((plasma and (atomic adj layer adj deposition) and		
		silicide) not (ALD and plasma and silicide))) and plasma		
55	114	438/651.ccls.	USPAT;	2004/10/22 15:01.
		100,001.001.	US-PGPUB;	200 11 10/22 15:01:
		·	EPO;	
			DERWENT;	
			IBM TDB	
56	,	420/651 cals, and fold on fatomic additionary addi	_	2004/10/22 15:01
30	I	438/651.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:01
		deposition))	US-PGPUB;	
			EPO;	
			DERWENT;	
			IBM_TDB	
57	0	(438/651.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:01
		deposition))) not (438/650.ccls. and (ald or (atomic adj	US-PGPUB;	
		layer adj deposition))) not (438/649.ccls. and (ald or	EPO;	
		(atomic adj layer adj deposition))) not (438/648.ccls. and	DERWENT;	
		(ald or (atomic adj layer adj deposition))) not	IBM_TDB	
		(438/630.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/597.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/686.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/685.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/683.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/682.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (ALD and plasma and silicide)		
		not ((plasma and (atomic adj layer adj deposition) and		
		silicide) not (ALD and plasma and silicide))		
58	903	438/655.ccls.	USPAT;	2004/10/22 15:02
			US-PGPUB;	,
			EPO;	
			DERWENT;	
		·	IBM TDB	
59	3	438/655.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:02
J /	3	deposition))	US-PGPUB;	2007/10/22 13.02
	1	deposition)	EPO;	
	1		DERWENT;	
	1		IBM_TDB	ļ

		(100//57 1 1/11 /	I v von v m	[
60	0	(438/655.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:02
		deposition))) not (438/651.ccls. and (ald or (atomic adj	US-PGPUB;	
		layer adj deposition))) not (438/650.ccls. and (ald or	EPO;	
•		(atomic adj layer adj deposition))) not (438/649.ccls. and	DERWENT;	
		(ald or (atomic adj layer adj deposition))) not	IBM_TDB	
	•	(438/648.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/630.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/597.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/686.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/685.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/683.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/682.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (ALD and plasma		
		and silicide) not ((plasma and (atomic adj layer adj		
		deposition) and silicide) not (ALD and plasma and		
		silicide)) .		
61	895	438/656.ccls.	USPAT;	2004/10/22 15:03
			US-PGPUB;	
			EPO;	
			DERWENT;	
			IBM_TDB	
62	17	438/656.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:03
		deposition))	US-PGPUB;	
			EPO;	
			DERWENT;	
			IBM_TDB	
63	3	(438/656.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:03
]	deposition))) not (438/655.ccls. and (ald or (atomic adj	US-PGPUB;	
		layer adj deposition))) not (438/651.ccls. and (ald or	EPO;	
		(atomic adj layer adj deposition))) not (438/650.ccls. and	DERWENT;	
		(ald or (atomic adj layer adj deposition))) not	IBM_TDB	
		(438/649.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/648.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/630.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/597.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/686.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/685.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/683.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/682.ccls. and		
]	(ald or (atomic adj layer adj deposition))) not (ALD and		
		plasma and silicide) not ((plasma and (atomic adj layer		
		adj deposition) and silicide) not (ALD and plasma and		
]	silicide))		

	,	//100/252	LICDATE	0004/10/00 15 00
64	1	((438/656.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:03
		deposition))) not (438/655.ccls. and (ald or (atomic adj	US-PGPUB;	
		layer adj deposition))) not (438/651.ccls. and (ald or	EPO;	
		(atomic adj layer adj deposition))) not (438/650.ccls. and	DERWENT;	
		(ald or (atomic adj layer adj deposition))) not	IBM_TDB	
		(438/649.ccls. and (ald or (atomic adj layer adj		-
		deposition))) not (438/648.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/630.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/597.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/686.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/685.ccls. and (ald or (atomic adj		, ,
		layer adj deposition))) not (438/683.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/682.ccls. and		
		(ald or (atomic adj layer adj deposition))) not (ALD and		
		plasma and silicide) not ((plasma and (atomic adj layer		
		adj deposition) and silicide) not (ALD and plasma and		
		silicide))) and plasma		
65	127	438/676.ccls.	USPAT;	2004/10/22 15:04
			US-PGPUB;	
			EPO;	
			DERWENT;	
			IBM TDB	
66	5	438/676.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:04
	_	deposition))	US-PGPUB;	
			EPO;	
			DERWENT;	
			IBM_TDB	
67	2	(438/676.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:04
·		deposition))) not (438/656.ccls. and (ald or (atomic adj	US-PGPUB;	
		layer adj deposition))) not (438/655.ccls. and (ald or	EPO;	
		(atomic adj layer adj deposition))) not (438/651.ccls. and	DERWENT;	
		(ald or (atomic adj layer adj deposition))) not	IBM_TDB	
		(438/650.ccls. and (ald or (atomic adj layer adj	15.11_155	
		deposition))) not (438/649.ccls. and (ald or (atomic adj		
	1	layer adj deposition))) not (438/648.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/630.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/597.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/686.ccls. and (ald or (atomic adj	ł	
		layer adj deposition))) not (438/685.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/683.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/682.ccls. and (ald or (atomic adj layer adj		_
]
		deposition))) not (ALD and plasma and silicide) not		
		((plasma and (atomic adj layer adj deposition) and		
	L	silicide) not (ALD and plasma and silicide))	l	L

deposition) not (438/65.ccls. and fald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition))) not (438/65.ccls. and (ald or (atomic adj layer adj deposition)) not (438/65.ccls. and (ald or (atomic adj layer adj deposition)) not (438/65.ccls. and (ald or (atomic adj layer adj d					
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			EPO;	
			DERWENT;	
		/	IBM_TDB	
77	0	(438/761.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:05
		deposition))) and (438/758.ccls. and (ald or (atomic adj	US-PGPUB;	
		layer adj deposition))) not (438/677.ccls. and (ald or	EPO;	
		(atomic adj layer adj deposition))) and (438/676.ccls.	DERWENT;	
		and (ald or (atomic adj layer adj deposition))) not	IBM_TDB	
		(438/656.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/655.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/651.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/650.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/649.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/648.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/630.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/597.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/686.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/685.ccls. and (ald or (atomic adj		,
		layer adj deposition))) not (438/683.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/682.ccls. and		
		(ald or (atomic adj layer adj deposition))) not (ALD and		
		plasma and silicide) not ((plasma and (atomic adj layer		
		adj deposition) and silicide) not (ALD and plasma and		
70	070	silicide))	LICDATE	0004/10/00 15 01
78	278	438/762.ccls.	USPAT;	2004/10/22 15:06
			US-PGPUB;	
			EPO;	
			DERWENT;	
	<u> </u>		IBM_TDB	

79	2	438/762.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:06
		deposition))	US-PGPUB;	
			EPO;	
			DERWENT;	
			IBM_TDB	
80	0	(438/762.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:06
		deposition))) not (438/761.ccls. and (ald or (atomic adj	US-PGPUB;	Ì
		layer adj deposition))) and (438/758.ccls. and (ald or	EPO;	
		(atomic adj layer adj deposition))) not (438/677.ccls. and	DERWENT;	
		(ald or (atomic adj layer adj deposition))) and	IBM_TDB	
		(438/676.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/656.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/655.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/651.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/650.ccls. and (ald or (atomic adj layer adj		
•		deposition))) not (438/649.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/648.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/630.ccls. and (ald or (atomic adj layer adj deposition))) not		
		(438/597.ccls. and (ald or (atomic adj layer adj		•
	İ	deposition))) not (438/686.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/685.ccls. and (ald or	,	
		(atomic adj layer adj deposition))) not (438/683.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/682.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (ALD and plasma and silicide) not		
		((plasma and (atomic adj layer adj deposition) and		
		silicide) not (ALD and plasma and silicide))		
81	954	438/763.ccls.	USPAT;	2004/10/22 15:06
			US-PGPUB;	, ,
			EPO;	
		,	DERWENT;	
			IBM_TDB	
82	20	438/763.ccls. and (ald or (atomic adj layer adj	USPĀT;	2004/10/22 15:06
		deposition))	US-PGPUB;	
		'	EPO;	
			DERWENT;	
			IBM TDB	

83	0	(438/763.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:07
		deposition))) not (438/762.ccls. and (ald or (atomic adj	US-PGPUB;	
-		layer adj deposition))) not (438/761.ccls. and (ald or	EPO;	
		(atomic adj layer adj deposition))) and (438/758.ccls.	DERWENT;	
ĺ		and (ald or (atomic adj layer adj deposition))) not	IBM TDB	
		(438/677.ccls. and (ald or (atomic adj layer adj	_	.
		deposition))) and (438/676.ccls. and (ald or (atomic adj		·
		layer adj deposition))) not (438/656.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/655.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
,		(438/651.ccls. and (ald or (atomic adj layer adj		
ĺ		deposition))) not (438/650 ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/649.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/648.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/630.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/597.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/686.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/685.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/683.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/682.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (ALD and plasma and silicide)		
		not ((plasma and (atomic adj layer adj deposition) and		
		silicide) not (ALD and plasma and silicide))		
84	148	438/765.ccls.	USPAT;	2004/10/22 15:07
	1 10		US-PGPUB;	200 4 10/22 13.07
			EPO;	
			DERWENT;	
			IBM TDB	
85	8	438/765.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:07
~~		deposition))	US-PGPUB;	2004/10/22 13.07
		deposition)	EPO;	
			DERWENT;	
			IBM TDB	

86	0	(438/765.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:07
		deposition))) and (438/763.ccls. and (ald or (atomic adj	US-PGPUB;	
		layer adj deposition))) not (438/762.ccls. and (ald or	EPO:	
		(atomic adj layer adj deposition))) not (438/761.ccls. and	DERWENT;	
		(ald or (atomic adj layer adj deposition))) and	IBM TDB	:
		(438/758.ccls. and (ald or (atomic adj layer adj	_	•
		deposition))) not (438/677.ccls. and (ald or (atomic adj		
		layer adj deposition))) and (438/676.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/656.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/655.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/651.ccls. and (ald or (atomic adj		
	1	layer adj deposition))) not (438/650.ccls. and (ald or		,
		(atomic adj layer adj deposition))) not (438/649.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/648.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/630.ccls. and (ald or (atomic adj		
	1	layer adj deposition))) not (438/597.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/686.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/685.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/683.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/682.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (ALD and plasma		
		and silicide) not ((plasma and (atomic adj layer adj		
		deposition) and silicide) not (ALD and plasma and		
		silicide))		
87	230	438/769.ccls.	USPAT;	2004/10/22 15:07
			US-PGPUB;	
			EPO;	
			DERWENT;	
00		400/740 1 1/11 /	IBM_TDB	
88	9	438/769.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:07
		deposition))	US-PGPUB;	
			EPO;	
			DERWENT;	
			IBM_TDB	

89	0	(438/769.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:07
		deposition))) not (438/765.ccls. and (ald or (atomic adj	US-PGPUB;	
		layer adj deposition))) and (438/763.ccls. and (ald or	EPO:	
		(atomic adj layer adj deposition))) not (438/762.ccls. and	DERWENT;	
		(ald or (atomic adj layer adj deposition))) not	IBM_TDB	
		(438/761 ccls. and (ald or (atomic adj layer adj	_	
		deposition))) and (438/758.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/677.ccls. and (ald or		
		(atomic adj layer adj deposition))) and (438/676.ccls.		
		and (ald or (atomic adj layer adj deposition))) not		
		(438/656.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/655.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/651.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/650.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/649.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/648.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/630.ccls. and (ald or		İ
		(atomic adj layer adj deposition))) not (438/597.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/686.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/685.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/683.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/682.ccls. and		
		(ald or (atomic adj layer adj deposition))) not (ALD and		
		plasma and silicide) not ((plasma and (atomic adj layer		
		adj deposition) and silicide) not (ALD and plasma and		
		silicide))		
90	967	438/778.ccls.	USPAT;	2004/10/22 15:08
			US-PGPUB;	
			EPO;	
			DERWENT;	
			IBM_TDB	
91	51	438/778.ccls. and (ald or (atomic adj layer adj	USPĀT;	2004/10/22 15:08
		deposition))	US-PGPUB;	
		-	EPO;	
			DERWENT;	
	1		IBM TDB	

92	0	(438/778.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:08
		deposition))) not (438/769.ccls. and (ald or (atomic adj	US-PGPUB;	
		layer adj deposition))) not (438/765.ccls. and (ald or	EPO;	
		(atomic adj layer adj deposition))) and (438/763.ccls.	DERWENT;	
		and (ald or (atomic adj layer adj deposition))) not	IBM_TDB	
		(438/762.ccls. and (ald or (atomic adj layer adj	_	
		deposition))) not (438/761.ccls. and (ald or (atomic adj		
		layer adj deposition))) and (438/758.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/677.ccls. and		
		(ald or (atomic adj layer adj deposition))) and		
		(438/676.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/656.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/655.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/651.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/650.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/649.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/648.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/630.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/597.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/686.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/685.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/683.ccls. and		,
		(ald or (atomic adj layer adj deposition))) not		
		(438/682.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (ALD and plasma and silicide) not		
		((plasma and (atomic adj layer adj deposition) and		
		silicide) not (ALD and plasma and silicide))		
93	535	438/785.ccls.	USPAT;	2004/10/22 15:08
			US-PGPUB;	
		·	EPO;	
			DERWENT;	
		· ·	IBM_TDB	
94	102	438/785.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:08
		deposition))	US-PGPUB;	
			EPO;	
			DERWENT;	
			IBM_TDB	

95	0	(438/785.ccls. and (ald or (atomic adj layer adj	USPAT;	2004/10/22 15:08
		deposition))) not (438/778.ccls. and (ald or (atomic adj	US-PGPUB;	
		layer adj deposition))) not (438/769.ccls. and (ald or	EPO;	
		(atomic adj layer adj deposition))) not (438/765.ccls. and	DERWENT;	
		(ald or (atomic adj layer adj deposition))) and	IBM_TDB	,
		(438/763.ccls. and (ald or (atomic adj layer adj	_	
		deposition))) not (438/762.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/761.ccls. and (ald or		
		(atomic adj layer adj deposition))) and (438/758.ccls.		
		and (ald or (atomic adj layer adj deposition))) not		
		(438/677.ccls. and (ald or (atomic adj layer adj		
		deposition))) and (438/676.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/656.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/655.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/651.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/650.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/649.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/648.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/630.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/597.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/686.ccls. and (ald or		
		(atomic adj layer adj deposition))) not (438/685.ccls. and		
		(ald or (atomic adj layer adj deposition))) not		
		(438/683.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/682.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (ALD and plasma and silicide)		
		not ((plasma and (atomic adj layer adj deposition) and		
		silicide) not (ALD and plasma and silicide))		

96	0	(("4796082" "5593562"	USPAT; US-PGPUB;	2004/10/22 15:08
		"4568960"	EPO;	
		"5217943"	DERWENT;	
		"6576062"	IBM_TDB	
		"6773970"		
		"6703296"		
		"5320880"		
		"5652181"		
		"5882399"		
	İ	"6420260"		
		"4557943"		
		"4617237"		
•		"4443930"		
	'	"4568565"		
		"5719410"		
		"4978420"		
		"5236868"		
		"5403435"		
		"5478780"		
		"5928966"		
		"6100193"		
		"4411734"		
		"5246887"		
		"5344792"		
		"5554488"		
		"5686761"		
		"5693562"		
		"5736455"		
		"5801095"		
		"5849092"		
		"5904561"		
		"5926743"		
		"5933760"		
		"5990493"		
		"5994211"		
		"6026762"		
		"6117345"		
		"6146988"		
		"6204550"		
		"4453305"		
		"4464701"		
		"4570328"		
		"4605947"		
		"4777061"		
		"4777150"		
		"4786360"		
		"4795722"		
		"4839304"		
		"4894693").pn.		
) not (438/785.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/778.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/769.ccls. and (ald or		,
		(atomic adj layer adj deposition))) not (438/765.ccls. and		
		(ald or (atomic adj layer adj deposition))) and	1	
		(438/763.ccls. and (ald or (atomic adj layer adj		
		deposition))) not (438/762.ccls. and (ald or (atomic adj		
		layer adj deposition))) not (438/761.ccls. and (ald or		
		(atomic adj layer adj deposition))) and (438/758.ccls.		
		and (ald or (atomic adj layer adj deposition))) not		
1		-/400//7711/11 /		
earch Histo	ry 10/22/04	denosition))) and (438/676 cels and (ald or (atomic ad)		
:\APPS\EAS	T\Workspace	deposition))) and (438/676.ccls. and (ald or (atomic adj s9958 (sp.))) not (438/656.ccls. and (ald or		
	-	laver and deposition (1) not (438/656 ccls, and (ald or		